

### PATENT APPLICATION TRANSMITTAL LETTER

Assistant Commissioner for Patents Washington, D.C. 20231

Transmitted herewith for filing is the patent application of:

	Takeshi KONDO, Kazuhiro TAKAHASHI and Yoshihisa MINEURA
Entitled:	"PRESSURE SENSITIVE ADHESIVE SHEET AND METHOD OF USE THEREOF"

Enclosed are:

sheets of drawings

An Assignment of the invention to: LINTEC CORPORATION

Declaration and Power of Attorney

Preliminary Amendment

Claim for Priority with certified copy

#### CLAIMS AS FILED

No. Filed No. Extra	Small Entity Rate	Non-Small Entity Rate	Charge
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An original and two copies of this sheet are enclosed.

May 28, 1999 Date

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IN RE APPLICATION OF:

ATTORNEY DOCKET NUMBER

TAKESHI KONDO, KAZUHIRO TAKAHASHI and YOSHIHISA MINEURA

1217-990766

ENTITLED

# "PRESSURE SENSITIVE ADHESIVE SHEET AND METHOD OF USE THEREOF"

### TO BOX PATENT APPLICATION

Assistant Commissioner for Patents Washington D.C. 20231

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Nora Ann Pastrick
(Typed name of person mailing paper or fee)

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IN	RE	APPLICATI	ON OF:	

ATTORNEY DOCKET NUMBER

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KAZUHIRO TAKAHASHI
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TO BOX PATENT APPLICATION		
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#### PRELIMINARY AMENDMENT

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In re application of

TAKESHI KONDO, : PRESSURE SENSITIVE
KAZUHIRO TAKAHASHI : ADHESIVE SHEET AND
and YOSHIHISA MINEURA : METHOD OF USE THEREOF

Serial No. Not Yet Assigned :

Filed Concurrently Herewith

Pittsburgh, Pennsylvania

May 28, 1999

### PRELIMINARY AMENDMENT

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

Prior to examination, please amend the above-identified patent application as follows:

### IN THE SPECIFICATION:

Page 1, line 10, delete "irregularity" and insert therefor --irregular--.

Page 2, line 18, delete "to result" and insert therefor --resulting--.

Page 2, line 19, delete "Similar" and insert --A similar--.

Page 2, line 20, after "for", insert --the--.

Page 2, line 24, delete "called" and insert --referred to--.

Page 3, line 7, delete "OBJECT OF THE INVENTION".

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Page 3, line 12, delete "irregularity" and insert therefor --irregular--.

Page 4, line 14, delete "irregularity" and insert therefor --irregular--.

Page 13, line 25, delete "irregularity" and insert therefor --irregular--.

Page 14, line 14, delete "EFFECT OF THE INVENTION".

Page 14, line 18, delete "irregularity" and insert therefor --irregular--.

Page 15, line 10, delete "semicoductor" and insert therefor --semiconductor--.

### IN THE CLAIMS:

Please amend claim 3 as follows:

3. (Amended) A method of use of the pressure sensitive adhesive sheet claimed in claim 1 [or 2], comprising sticking the pressure sensitive adhesive sheet to a surface of an adherend and working the adherend at its back while protecting the adherend surface by means of the pressure sensitive adhesive sheet.

Please add new claim 4 as follows:

--4. A method of use of the pressure sensitive adhesive sheet claimed in claim 2, comprising sticking the pressure sensitive adhesive sheet to a surface of an adherend and working the adherend at its back while protecting the adherend surface by means of the pressure sensitive adhesive sheet.--

### N THE ABSTRACT:

Page 23, line 9, delete "irregularity" and insert therefor --irregular--.

#### REMARKS

Amendments have been made to the specification in order to correct certain grammatical and translational problems and to place the specification in conformance with standard United States patent practice. Claim 3 has been amended to eliminate the multiple dependency and claim 4 has been added to further define the invention.

Examination and allowance of pending claims 1-4 are respectfully requested.

Respectfully submitted,

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#### TITLE

PRESSURE SENSITIVE ADHESIVE SHEET AND METHOD OF USE THEREOF

### 5 FIELD OF THE INVENTION

The present invention relates to a pressure sensitive adhesive sheet. More particularly, the present invention relates to a pressure sensitive adhesive sheet which, at the time of working of the back of an adherend having a surface whose irregularity height differences are large, is preferably stuck to the adherend surface to thereby protect it during the working. The invention also relates to a method of use thereof.

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### BACKGROUND OF THE INVENTION

In the step of grinding the back of a semiconductor wafer, the surface thereof having electrical circuits formed thereon is protected by a pressure sensitive 20 adhesive sheet. The height differences of customary circuits attributed to electrode elements have ranged from about 5 to 20 µm. For the wafer having these customary circuits formed thereon, the conventional surface protective sheets can fully protect the circuits

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without the occurrence of circuit breakage or wafer cracking and thus have been satisfactory.

However, in recent years, the method of mounting IC chips is being diversified. For example, the packaging method in which an IC chip circuit surface is arranged down has been developed. In this packaging method, electrode elements protrude from the circuit surface and the height differences thereof are 30  $\mu$ m or more, occasionally greater than 100  $\mu$ m.

When the grinding of the back of the wafer having such protrudent electrode elements formed thereon is carried out while protecting the surface with the conventional surface protective sheet, it has been encountered that the back is deeply ground at portions corresponding the protrudent elements to thereby cause depressions (dimples) to occur on the back of the wafer. Further, it has been encountered that dimple portions crack to result in the breakage of the wafer.

Similar problem is encountered with respect to ink

(bad mark) provided for marking of failure circuits

after the inspection of the wafer circuits.

Protrudent portions formed on the surface of semiconductor wafers like those mentioned above are called as bumps. For the semiconductor wafers having large bumps, measures have been taken, which include,

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for example, decreasing the hardness of the substrate film of the surface protective sheet and increasing the thickness of the pressure sensitive adhesive sheet.

These measures, however, have been unsatisfactory, and the above problems have not yet been resolved.

### OBJECT OF THE INVENTION

The present invention has been made in view of the above state of the prior art. It is an object of the present invention to provide a pressure sensitive adhesive sheet which, at the time of working of the back of an adherend having a surface whose irregularity height differences are large, is preferably stuck to the adherend surface to thereby protect it during the working. And another object of the present invention is to provide a method of use thereof.

### SUMMARY OF THE INVENTION

The pressure sensitive adhesive sheet of the 20 present invention comprises a substrate and, superimposed thereon, a pressure sensitive adhesive layer, this substrate exhibiting a maximum value of dynamic viscoelasticity tan  $\delta$  of at least 0.5 at a temperature ranging from -5 to 80°C.

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It is preferred that the above substrate have a thickness and Young's modulus whose product is in the range of 0.5 to 100 kg/cm.

The present invention is also concerned with a method of use of the above pressure sensitive adhesive sheet comprising sticking the pressure sensitive adhesive sheet to a surface of an adherend and working the adherend at its back while protecting the adherend surface by means of the pressure sensitive adhesive sheet.

This invention provides a surface protective pressure sensitive adhesive sheet which can precisely follow the irregularities of an adherend surface to thereby absorb the irregularity height differences and which, at the time of grinding of the back of the adherend, enables accomplishing a smooth back grinding without being affected by the irregularities of the adherend surface.

### 20 <u>DETAILED DESCRIPTION OF THE INVENTION</u>

The present invention will be described in detail below.

The pressure sensitive adhesive sheet of the present invention comprises a substrate and,

superimposed thereon, a pressure sensitive adhesive layer.

The substrate exhibits a maximum value of dynamic viscoelasticity tan  $\delta$  (hereinafter simply referred to as 5 "tan  $\delta$  value") of at least 0.5, preferably 0.5 to 2.0, and still preferably 0.7 to 1.8 at a temperature ranging from -5 to 80°C. The terminology "tan  $\delta$ " used herein means the loss tangent which defines the ratio of loss elastic modulus/storage elastic modulus. It is measured 10 by the use of a dynamic viscoelasticity measuring instrument on the basis of response to a stress such as tension or torsion applied to an object.

In the present invention, it is preferred that the above substrate have a thickness and Young's modulus whose product is in the range of 0.5 to 100 kg/cm, especially 1.0 to 50 kg/cm, and still especially 2.0 to 40 kg/cm. The thickness of the substrate is preferably in the range of 30 to 1000  $\mu$ m, still preferably 50 to 800  $\mu$ m, and optimally 80 to 500  $\mu$ m.

The substrate is composed of a resin film, the type of which is not particularly limited as long as the above properties are exhibited. The above properties may be exhibited by either the resin per se or the resin blended with additives. The substrate may be prepared

25 by either conducting film formation by a curable resin

and curing the film or conducting film formation by a thermoplastic resin.

For example, a photocurable resin or a thermosetting resin is used as the curable resin.

5 Preferred is a photocurable resin.

The photocurable resin is preferably selected from among, for example, resin compositions whose principal component is a photopolymerizable urethane acrylate oligomer and polyene thiol resins.

- This urethane acrylate oligomer can be obtained by reacting an isocyanate-terminated urethane prepolymer which is obtained by reacting a polyester or polyether type polyol compound with a polyisocyanate compound such as 2,4-tolylene diisocyanate, 2,6-tolylene diisocyanate,
- 15 1,3-xylylene diisocyanate, 1,4-xylylene diisocyanate or diphenylmethane-4,4'-diisocyanate with an acrylate or methacrylate having hydroxyl group such as 2-hydroxyethyl acrylate, 2-hydroxyethyl methacrylate, 2-hydroxypropyl methacrylate,
- 20 polyethylene glycol acrylate or polyethylene glycol methacrylate. This urethane acrylate oligomer has a photopolymerizable double bond in its molecule and undergoes polymerization and curing when irradiated with light to thereby form a film.

The molecular weight of urethane acrylate oligomers preferably used in the present invention is in the range of 1000 to 50,000, especially 2000 to 30,000. These urethane acrylate oligomers can be used either

It is often difficult to obtain a film only from

5 individually or in combination.

the above urethane acrylate oligomer. Thus, films are generally obtained by diluting the urethane acrylate oligomer with a photopolymerizable monomer, conducting a film formation and curing the film. The photopolymerizable monomer has a photopolymerizable double bond in its molecule, and, in the present invention, preferred is an acrylic ester compound having a relatively bulky group.

The photopolymerizable monomer employed for diluting the urethane acrylate oligomer is, for example, selected from among:

alicyclic compounds such as isobornyl (meth)acrylate, dicyclopentenyl (meth)acrylate,

aromatic compounds such as benzyl acrylate; and heterocyclic compounds such as tetrahydrofurfuryl

25 (meth) acrylate, morpholinyl acrylate, N-

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vinylpyrrolidone and N-vinylcaprolactam. According to necessity, polyfunctional (meth)acrylates may be used.

The above photopolymerizable monomer is preferably added in an amount of 5 to 900 parts by weight, still preferably 10 to 500 parts by weight, and optimally 30 to 200 parts by weight to 100 parts by weight of the urethane acrylate oligomer.

On the other hand, the polyene thiol resin for use in the production of the substrate is formed from a polyene compound having no acryloyl group and a polythiol compound. Specifically, the polyene compound is selected from among, for example, diacrolein pentaerythritol, trimethylolpropane diallyl ether adduct of tolylene diisocyanate and unsaturated allylurethane oligomer. Mercaptoacetic acid or mercaptopropionic acid ester of pentaerythritol can preferably be used as the polythiol compound. Furthermore, commercially available polyene polythiol oligomers can be used. The molecular weight of the polyene thiol resin for use in the present invention is preferably in the range of 3000 to 50,000, still preferably 5000 to 30,000.

In the forming of the substrate from the photocurable resin, the time spent by polymerization and curing effected by photoirradiation and the

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photoirradiation dose can be reduced by mixing a photopolymerization initiator into the resin.

This photopolymerization initiator can be a photoinitiator such as a benzoin compound, an acetophenone compound, an acylphosphine oxide compound, a titanocene compound, a thioxanthone compound or a peroxide compound or a photosensitizer such as an amine or a quinone. Specific examples thereof include 1-hydroxycyclohexyl phenyl ketone, benzoin, benzoin methyl ether, benzoin ethyl ether, benzoin isopropyl ether, benzyl diphenyl sulfide, tetramethylthiuram monosulfide, azobisisobutyronitrile, dibenzyl, diacetyl and  $\beta$ -chloroanthraquinone.

The photopolymerization initiator is preferably

15 added in an amount of 0.05 to 15 parts by weight, still

preferably 0.1 to 10 parts by weight, and optimally 0.5

to 5 parts by weight to 100 parts by weight of the resin

total.

In the production of the above curable resin,

20 oligomer and monomer can be selected from among various combinations so that the above properties can be realized.

The thermoplastic resin for use in the substrate can be selected from among, for example, polyolefin resins such as polyethylene, polypropylene, polybutene,

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polybutadiene, polymethylpentene, polyvinyl chloride, polyvinylidene chloride, nonhydrogenated styrene-vinylisoprene block copolymer and hydrogenated thereof. Of these, nonhydrogenated or hydrogenated styrene-

5 vinylisoprene block copolymer is preferred.

The styrene-vinylisoprene block copolymer is generally an SIS (styrene-isoprene- styrene block copolymer) having a high content vinyl group. Both the nonhydrogenated and the hydrogenated styrene-

10 vinylisoprene block copolymer per se exhibit a high peak of tan  $\delta$  at about room temperature.

Additives capable of enhancing the tan  $\delta$  value are preferably added to the above resin. Examples of the additives capable of enhancing the tan  $\delta$  value include inorganic fillers such as calcium carbonate, silica and mica and metal fillers such as iron and lead. Especially, the addition of metal fillers having a high specific gravity is effective.

Further, the substrate may contain other additives,

20 for example, plasticizers or colorants such as pigments
and dyes in addition to the above components.

With respect to the film forming method, for example, the substrate can be produced by first casting a liquid resin (for example, noncured resin or resin solution) onto a processing sheet in the form of a thin

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film and subsequently conducting given steps for film formation by means of appropriate way corresponding to resin type. In this method, the stress upon the resin during the film formation is slight, so that the occurrence of fish-eye (insoluble portion of the resin components) is slight. Moreover, the uniformity of the film thickness is high and the thickness precision generally falls within 2%.

Another preferred method of forming a film

10 comprises calendering or extrusion forming with the use
of T die or tubular film method.

Corona treatment or superimposition of another layer such as primer may be effected on an upper surface, namely the side furnished with the pressure sensitive adhesive layer, of the substrate in order to enhance the adherence to the pressure sensitive adhesive layer between the substrates.

The pressure sensitive adhesive sheet of the present invention is produced by superimposing the pressure sensitive adhesive layer on the above substrate. When the pressure sensitive adhesive layer is composed of an ultraviolet curable pressure sensitive adhesive, a transparent substrate is used.

The pressure sensitive adhesive layer can be formed from various conventional pressure sensitive adhesives.

These pressure sensitive adhesives are not limited and, for example, any of rubber, acrylic, silicone and polyvinyl ether based pressure sensitive adhesives can be used. Further, radiation curable, thermally foaming and water swellable pressure sensitive adhesives can be used.

Although depending on the type of employed material, the thickness of the pressure sensitive adhesive layer is generally in the range of about 3 to 100  $\mu$ m, preferably about 10 to 50  $\mu$ m.

Various pressure sensitive adhesives can be used as the above pressure sensitive adhesive without any particular limitation. Those described in, for example, Japanese Patent Publication No. 1(1989)-56112 and

- Japanese Patent Laid-open Publication No. 7(1995) 135189 are preferably used as the radiation curable
  (light curable, ultraviolet curable or electron beam
  curable) pressure sensitive adhesive, which, however, is
  not limited thereto. In the present invention, it is
- 20 especially preferred to employ ultraviolet curable pressure sensitive adhesives. Moreover, those described in, for example, Japanese Patent Publication No. 5(1993)-77284 and Japanese Patent Publication No. 6(1994)-101455 are preferably used as the water
- 25 swellable pressure sensitive adhesive.

The pressure sensitive adhesive sheet of the present invention can be obtained by coating a variable substrate in appropriate thickness with the above pressure sensitive adhesive according to the customary technique employing a knife roll coater, a gravure coater, a die coater, a reverse coater or the like and drying the pressure sensitive adhesive to thereby form a pressure sensitive adhesive layer on the substrate.

When considered necessary, a release liner is applied onto the pressure sensitive adhesive layer.

The pressure sensitive adhesive sheet of the present invention is used to protect the surface of various items and to effect temporary fixing at the time of precision working. In particular, the pressure sensitive adhesive sheet is suitably used as one for protecting the circuit surface during the grinding of the back of semiconductor wafers. The pressure sensitive adhesive sheet of the present invention is furnished with the substrate possessing the above specified properties and hence effectively absorbs the irregularities of the circuit surface. Therefore, the pressure sensitive adhesive sheet of the present invention can not only be stuck with satisfactory adherence to wafers provided with bumps and the like and

25 thus having large surface irregularity height

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differences but also mitigate the influence of the irregularities of the wafer surface on the back grinding to thereby enable not only prevention of the wafer breakage but also attaining an extremely smooth grinding. Moreover, when the pressure sensitive adhesive layer is composed of, for example, the ultraviolet curable pressure sensitive adhesive, the adhesive strength can be easily reduced by ultraviolet irradiation, so that, after the completion of required working, the pressure sensitive adhesive layer can be easily stripped off by irradiating the pressure sensitive adhesive adhesive layer with ultraviolet rays.

### EFFECT OF THE INVENTION

This invention provides a surface protective pressure sensitive adhesive sheet which can precisely follow the irregularities of an adherend surface to thereby absorb the irregularity height differences and which, at the time of grinding of the back of the adherend, enables accomplishing a smooth back grinding without being affected by the irregularities of the adherend surface.

#### EXAMPLE

The present invention will further be illustrated below with reference to the following Examples which in no way limit the scope of the invention.

In the following Examples and Comparative Examples,

the "back grinding aptitude test" was carried out in the
following manner.

### Back grinding aptitude test

The following dotted bad marks by printing as bumps were provided on a specular surface of 6-inch

- semicoductor wafer. Each pressure sensitive adhesive sheet was stuck to the surface of the wafer on which the bad marks were provided, and the opposite surface of the wafer was ground. The wafer configuration, grinding conditions and evaluation method were as follows:
- 15 (1) Wafer configuration

thickness of wafer (thickness of portion where no dot was printed): 650 to 700  $\mu m_{\star}$ 

dot diameter: 500 to 600 µm,

dot height: 70 µm, and

- 20 dot pitch: 10 mm interval (overall printing);
  - (2) Back grinding conditions

finished thickness: 200 µm, and

grinding apparatus: grinder DFG 840 manufactured by Disco Corporation; and

25 (3) Evaluation method

Ground wafer back was observed. When there was no crack or dimple or when dimples were observed but the maximum depth thereof was less than 2  $\mu m$ , the wafer was evaluated as "good". On the other hand, when dimples were observed and the maximum depth thereof was 2  $\mu m$  or more, the wafer was evaluated as "dimpled".

The tan  $\delta$  was measured by a dynamic viscoelasticity measuring instrument at a 110 Hz tensile stress. Specifically, each substrate was sampled into a predetermined size, and the tan  $\delta$  was measured at a frequency of 110 Hz and at temperature ranging from -40 to 150°C with the use of Rheovibron DDV-11-EP manufactured by Orientec Corporation. The maximum value of measured tan  $\delta$  at temperature ranging from -5 to 80°C was employed as "tan  $\delta$  value".

The Young's modulus was measured at a test speed of 200 mm/min in accordance with Japanese Industrial Standard K7127.

#### Example 1

50 parts by weight of urethane acrylate oligomer having a weight average molecular weight of 5000 (produced by Arakawa Chemical Industry Co., Ltd.), 50 parts by weight of isobornyl acrylate, 2.0 parts by weight of photopolymerization initiator (Irgacure 184 produced by Ciba-Geigy, Limited) and 0.2 part by weight

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of phthalocyanine pigment were blended together, thereby obtaining a photocurable resin composition.

Polyethylene terephthalate (PET) film (produced by Toray Industries, Inc., thickness: 38  $\mu m)$  as a casting processing sheet was coated with the above resin composition at a thickness of 110  $\mu m$  according to the fountain die technique, thereby forming a resin composition layer. Immediately after the coating, the resin composition layer was laminated with the same PET film and thereafter irradiated with ultraviolet rays emitted from a high pressure mercury lamp (160 W/cm, distance 10 cm) at a dose of 250 mJ/cm² so that the resin composition layer was crosslinked and cured. Thus, a substrate film of 110  $\mu m$  thickness was obtained after peeling both the PET films. The tan  $\delta$  and Young's modulus of this substrate film were measured by the above methods. The results are given in Table 1.

pressure sensitive adhesive composition prepared by

20 blending together 100 parts by weight of acrylic'

pressure sensitive adhesive (copolymer of n-butyl

acrylate and acrylic acid), 120 parts by weight of

urethane acrylate oligomer whose molecular weight was

8000, 10 parts by weight of curing agent (diisocyanate

type compound) and 5 parts by weight of

One side of this substrate film was coated with a

photopolymerization initiator (benzophenone type compound), and dried so that a pressure sensitive adhesive layer of 20 µm thickness was formed. Thus, a pressure sensitive adhesive sheet was obtained.

The back grinding aptitude test of the obtained pressure sensitive adhesive sheet was conducted. The results are given in Table 1.

### Example 2

The same procedure as in Example 1 was repeated

10 except that morpholinyl acrylate was used in place of
isobornyl acrylate. The results are given in Table 1.

Example 3

The same procedure as in Example 1 was repeated except that a mixture of 25 parts by weight of isobornyl acrylate and 25 parts by weight of morpholinyl acrylate was used in place of 50 parts by weight of isobornyl acrylate. The results are given in Table 1.

### Example 4

A 60% toluene solution of styrene-vinylisoprene 20 block copolymer (Hybrar VS-1 produced by Kuraray Co., Ltd.) was cast on the same support film as in Example 1, and dried at 100°C for 2 minutes without lamination and, ultraviolet irradiation. Thus, a 300  $\mu$ m thick substrate film having the tan  $\delta$  value and Young's modulus listed

25 in Table 1 was obtained.

A pressure sensitive adhesive sheet was prepared from the obtained substrate film in the same manner as in Example 1. The back grinding aptitude test of the obtained pressure sensitive adhesive sheet was

5 conducted. The results are given in Table 1.

#### Example 5

In place of the photocurable resin composition of Example 1, polyene thiol resin (BY-314 produced by Asahi Denka Kogyo K.K.) was formed into a film and cured in the same manner as in Example 1, thereby obtaining a substrate film of 250  $\mu$ m thickness. The tan  $\delta$  and Young's modulus of this substrate film were measured by the above methods. The results are given in Table 1. A pressure sensitive adhesive sheet was prepared from the obtained substrate film in the same manner as in Example 1. The back grinding aptitude test of this pressure sensitive adhesive sheet was conducted. The results are given in Table 1.

#### Example 6

20 The same procedure as in Example 1 was repeated except that the amount of added urethane acrylate oligomer (produced by Arakawa Chemical Industry Co., Ltd.) was changed to 60 parts by weight and 50 parts by weight of N-vinylcaprolactam was used in place of 50

parts by weight of isobornyl acrylate. The results are given in Table 1.

#### Comparative Example 1

The same procedure as in Example 1 was repeated

5 except that 110 µm thick low-density polyethylene film

(trade name: Sumikathene L705) was used as the substrate

film. The results are given in Table 1.

### Comparative Example 2

The same procedure as in Example 1 was repeated  $10 \quad \text{except that a 100 } \mu\text{m thick film of ethylene/vinyl}$  acetate copolymer (vinyl acetate content: 12% by weight) was used as the substrate film. The results are given in Table 1.

#### Comparative Example 3

15 The same procedure as in Example 1 was repeated except that a 110 µm thick film of ethylene/methyl methacrylate copolymer (methyl methacrylate content: 6% by weight) was used as the substrate film. The results are given in Table 1.

### 20 Comparative Example 4

The same procedure as in Example 1 was repeated except that a 110  $\mu$ m thick film of ethylene/methacrylic acid copolymer (methacrylic acid content: 8% by weight) was used as the substrate film. The results are given

25 in Table 1.

### Comparative Example 5

The same procedure as in Example 1 was repeated except that a 100  $\mu m$  polyethylene terephthalate film was used as the substrate film. The results are given in Table 1.

Table 1

	Max.value of tan δ (-5 to 80°C)	Young's modulus (kg/cm <sup>2</sup> )	Film thickness (µm)	[FT]x[YM] (kg/cm)	Back grinding aptitude
Example 1	0.78	1100	110	12.1	good
2	0.85	2400	110	26.4	good
3	1.18	1400	110	15.4	good
4	1.05	100	300	3.0	good
5	1.61	120	250	3.0	good
6	0.81	3000	110	33.0	good
Comp.Ex.1	0.19	1300	110	14.3	dimpled, wafer broken
2	0.16	660	100	6.6	dimpled, wafer broken
3	0.21	900	110	9.9	dimpled
4	0.17	1300	80	10.4	dimpled, wafer broken
5	0.03	35000	100	350.0	dimpled, wafer broken

### <u>Note</u>

[FT]x[YM] means [film thickness]x[Young's modulus].

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#### What is claimed is:

- 1. A pressure sensitive adhesive sheet comprising a substrate and, superimposed thereon, a pressure sensitive adhesive layer, said substrate exhibiting a maximum value of dynamic viscoelasticity tan  $\delta$  of at least 0.5 at a temperature ranging from -5 to 80°C.
- 2. The pressure sensitive adhesive sheet as claimed in claim 1, wherein the substrate has a thickness and Young's modulus whose product is in the range of 0.5 to 100 kg/cm.
- 3. A method of use of the pressure sensitive adhesive sheet claimed in claim 1 or 2, comprising sticking the pressure sensitive adhesive sheet to a surface of an adherend and working the adherend at its back while protecting the adherend surface by means of the pressure sensitive adhesive sheet.

### **ABSTRACT**

The invention is concerned with a pressure sensitive adhesive sheet comprising a substrate and, superimposed thereon, a pressure sensitive adhesive 1 layer, said substrate exhibiting a maximum value of dynamic viscoelasticity tan  $\delta$  of at least 0.5 at a 1 temperature ranging from -5 to 80°C. At the time of working of the back of an adherend having a surface whose irregularity height differences are large, this 10 pressure sensitive adhesive sheet is preferably stuck to the adherend surface to thereby protect it during the working.

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"Express Mail" Label Number	EL308542473US
Date of Deposit	May 28, 1999
I hereby certify that the	e following attached paper or fee
APPLICATION (3 pp.),	R OF ATTORNEY FOR PATENT SPECIFICATION (21 pp.), and ABSTRACT (1 p.)
Mail Post Office to Addressee" the date indicated above and	ted States Postal Service "Express service under 37 C.F.R. §1.10 on d is addressed to the Assistant ademarks, Washington, D.C. 20231.
(Typed n	Nora Ann Pastrick ame of person mailing paper or fee)
100	re of person mailing paper or fee)

Page 1 of 3

## Declaration and Power of Attorney For Patent Application

### English Language Declaration

As a below named inventor, I hereby declare that:

My residence, post office address and citizenship are as stated below next to my name,

I believe I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed and for which a patent is sought on the invention entitled

	PRESSURE SENSITIVE	E ADHESIVE SHEET AND M	ETHOD OF USE THEREO	F		
the	specification of v	which				•
(che	eck one)					
X	is attached heret	0.				
	was filed on	al No				as
	Application Seria	al No.				
	and was amended or	n(if a	pplicable)			•
I adapp	cirication, include cknowledge the duty lication in accordance ereby claim foreign application(so ntified below any foreign application)	I have reviewed and using the claims, as ame to disclose information ance with Title 37, Congression priority benefits using the patent or investign application for the application on which	on which is materia de of Federal Regul nder Title 35, Unit ntor's certificate patent or inventor's	l to the ations, state listed	examinat: \$1.56(a). ss Code, spelow and	ion of this \$119 of any have also
	or Foreign Applica	tion(s)		<u>P</u> :	riority C	laimed
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	mber)	(Country)	(Day/Month/Year Fi	.led)	Yes	No
(Nu	mber)	(Country)	(Day/Month/Year Fi	led)	☐ Yes	□ No
(Nu	mber)	(Country)	(Day/Month/Year Fi	led)	□ Yes	□ No

I hereby claim the benefit under Title 35, United States Code, §120 of any United States application(s) listed below and, insofar as the subject matter of each of the claims of this application is not disclosed in the prior United States application in the manner provided by the first paragraph of Title 35, United States Code, §112, I acknowledge the duty to disclose material information as defined in Title 37, Code of Federal Regulations, §1.56(a) which occurred between the filing date of the prior application and the national or PCT international filing date of this application:

					Page 2 of 3
(Application Serial No.)	(Filing Da	ate)	(St (patented, pe	catus) ending, a	bandoned)
(Application Serial No.)	(Filing Da	ate)	(St	atus) ending, a	bandoned)
I hereby declare that all stateme statements made on information are statements were made with the known are punishable by fine or imprison States Code and that such willf application or any patent issued	nd belief are had belief that will ment, or both, will false state	pelieved to be llful false st under Section 1	true; and fu atements and 1001 of Title	rther the the like 18 of the	hat these e so made he United
David C. Bruening 20,742 Fred William H. Logsdon 22,132 Kent Russell D. Orkin 25,363 Barb David C. Hanson 23,024 Paul	tion and transa	ct all busines stration numbe 28,498 nheim 19,438 25,826	s in the Pater) Michael I. John W. McBlynn L. Sl Julie W. Me	ent and Shamos Ilvaine nideler eder	30,424 34,219 35,034 36,216
Send Correspondence to: Russell D. Orkin, 700 Koppers Bui	lding, 436 Seve	enth Avenue, P	ittsburgh PA	15219-1	818
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Post Office Address	5-3-17, Shiba,	, Kawaguchi-sh	i, Saitama 33	3-0866,	Japan

(Supply similar information and signature for third and subsequent joint inventors.)

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Third inventor's signature		a MINEURA		Date	
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Residence	Tokyo, Ja	pan			
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Full name of fourth joint inventor, if any					
Fourth inventor's signature		V4		Date	
Residence					
Citizenship					
Post Office Address	-				
A family				7 - A - A - A - A - A - A - A - A - A -	
			-		
Full name of fifth joint inventor, if any					
Fifth inventor's signature				Date	
Residence					
Citizenship		·		***************************************	
Post Office Address					
•					
Full name of sixth joint inventor, if any					
Sixth inventor's signature				Date	
Residence					
Citizenship					
Post Office Address					